

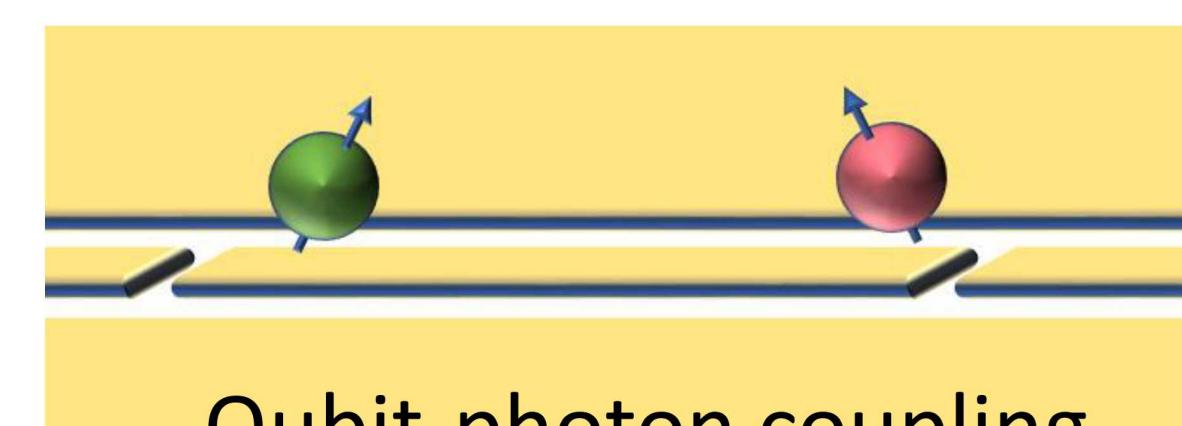


Development of NbTiN films for superconducting microwave resonators

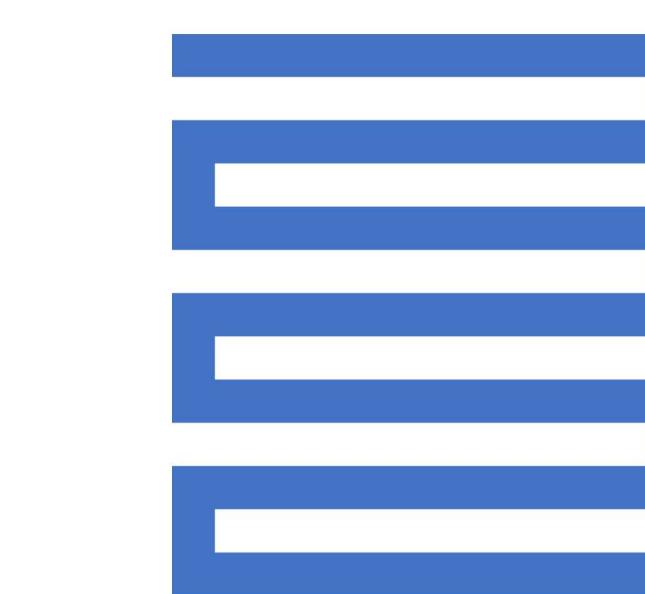
Tzu-Ming Lu, R. M. Lewis, P. A. Sharma, C. T. Harris, A. L. Lima-Sharma, Terence M. Bretz-Sullivan, David Lidsky, Sandia National Laboratories, New Mexico
Michael Venuti, Serena Eley, Colorado School of Mines

Motivation

NbTiN thin films find applications in quantum information science and quantum materials.



Qubit-photon coupling

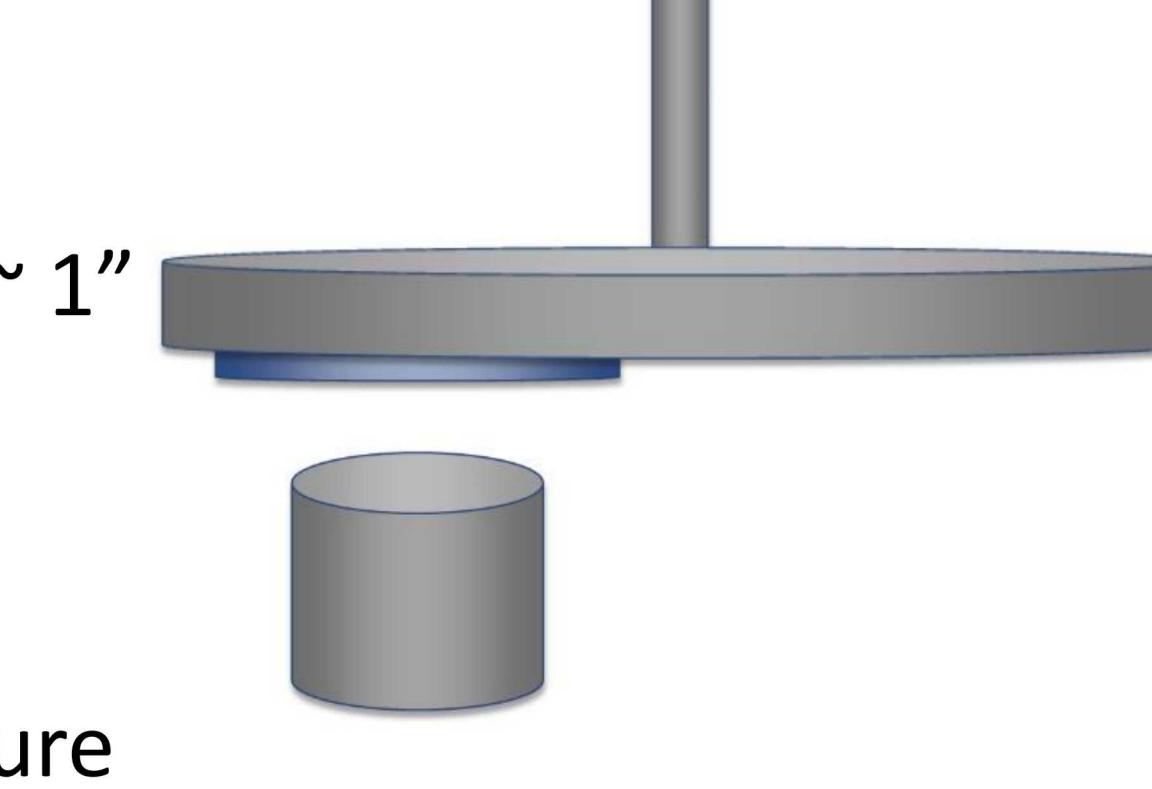


Induced superconductivity

Our goals are to establish processes for fabricating high quality factor microwave resonators using NbTiN thin films and correlate the resonator performance with material properties.

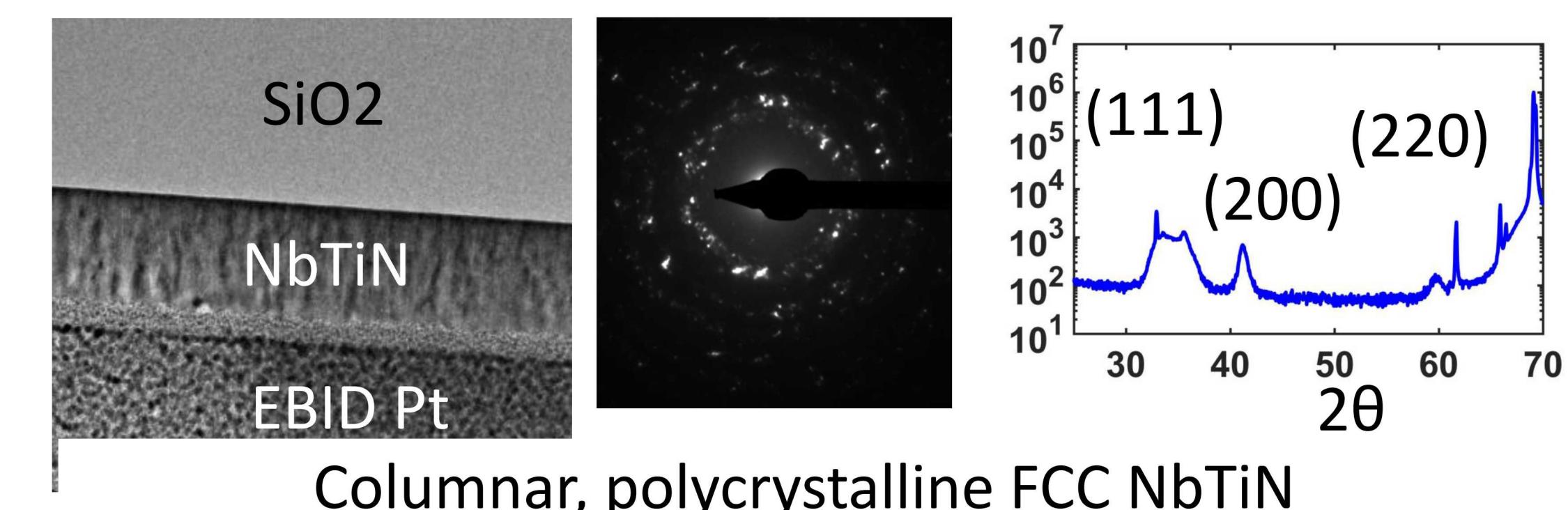
NbTiN Sputtering

- DC magnetron sputtering
- 3" NbTi target
- Ar + N₂
- Substrate-target spacing ~ 1"
- No substrate heating
- Variables:

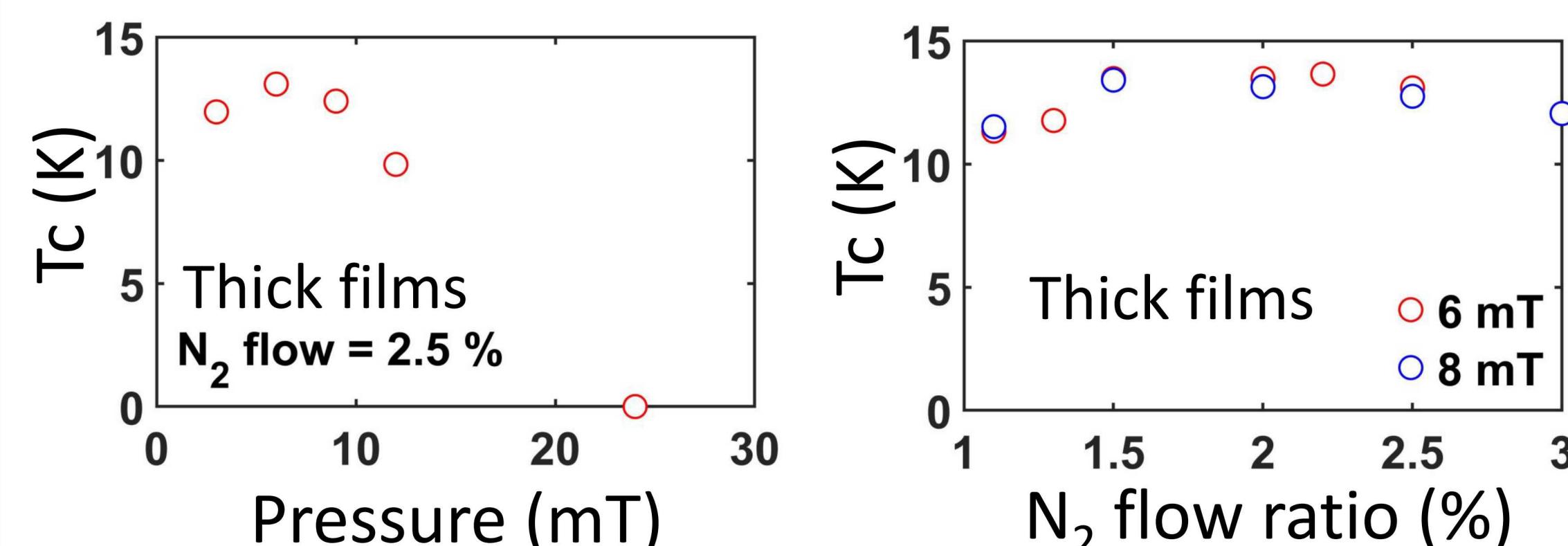


- N₂/Ar ratio
- Deposition pressure
- Deposition time (thickness)

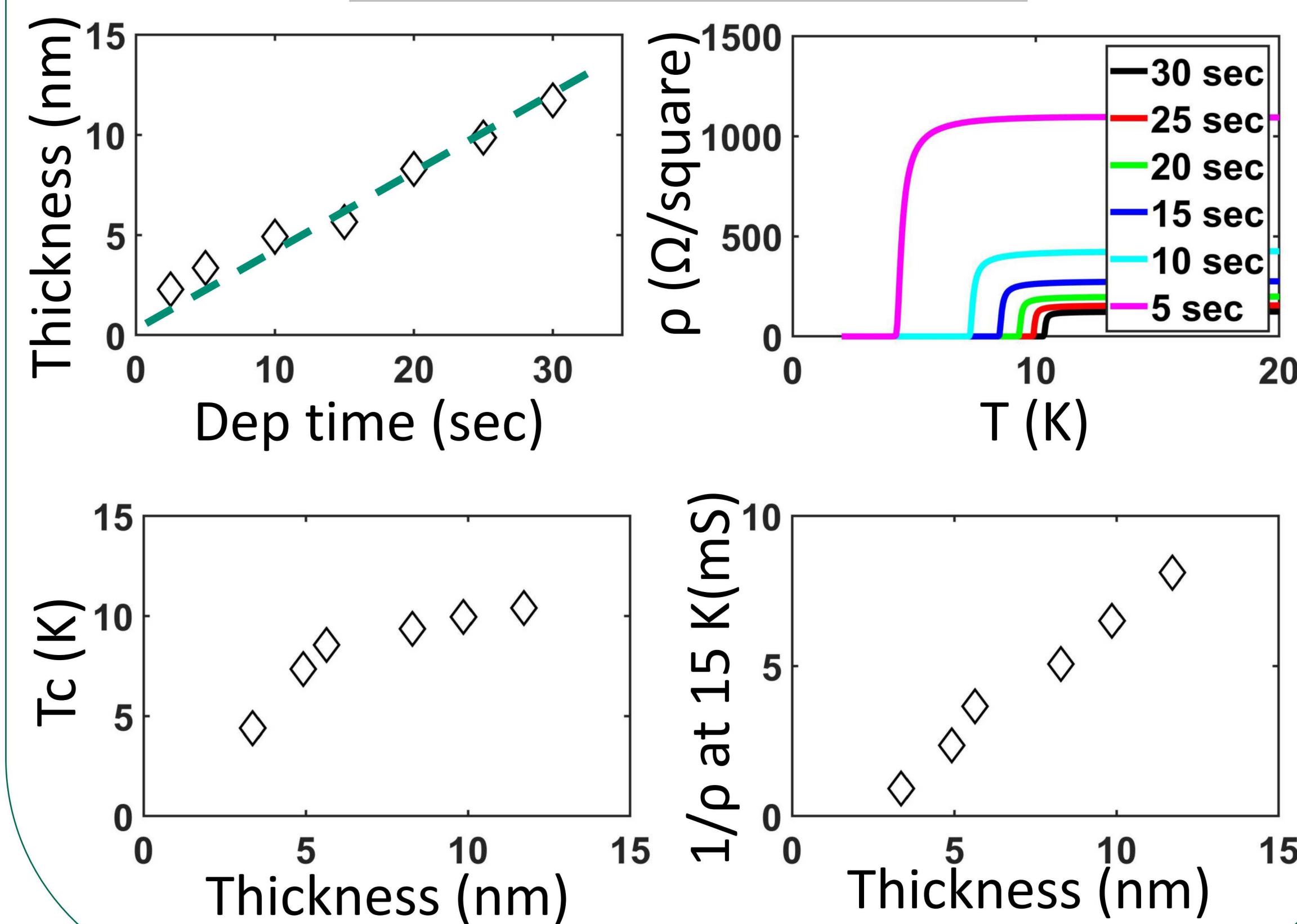
Materials characterizations



Optimization of deposition

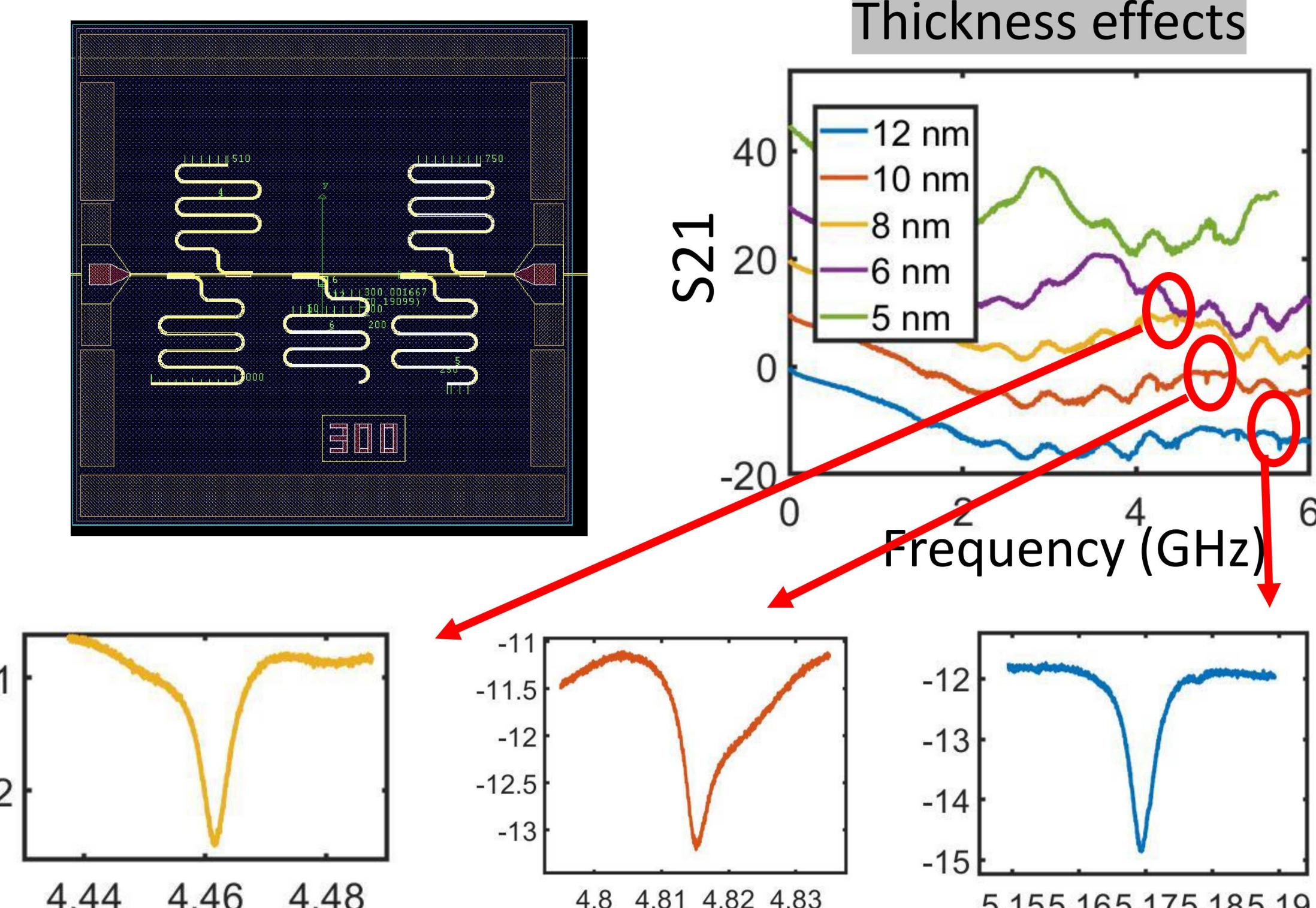


Ultra thin NbTiN films

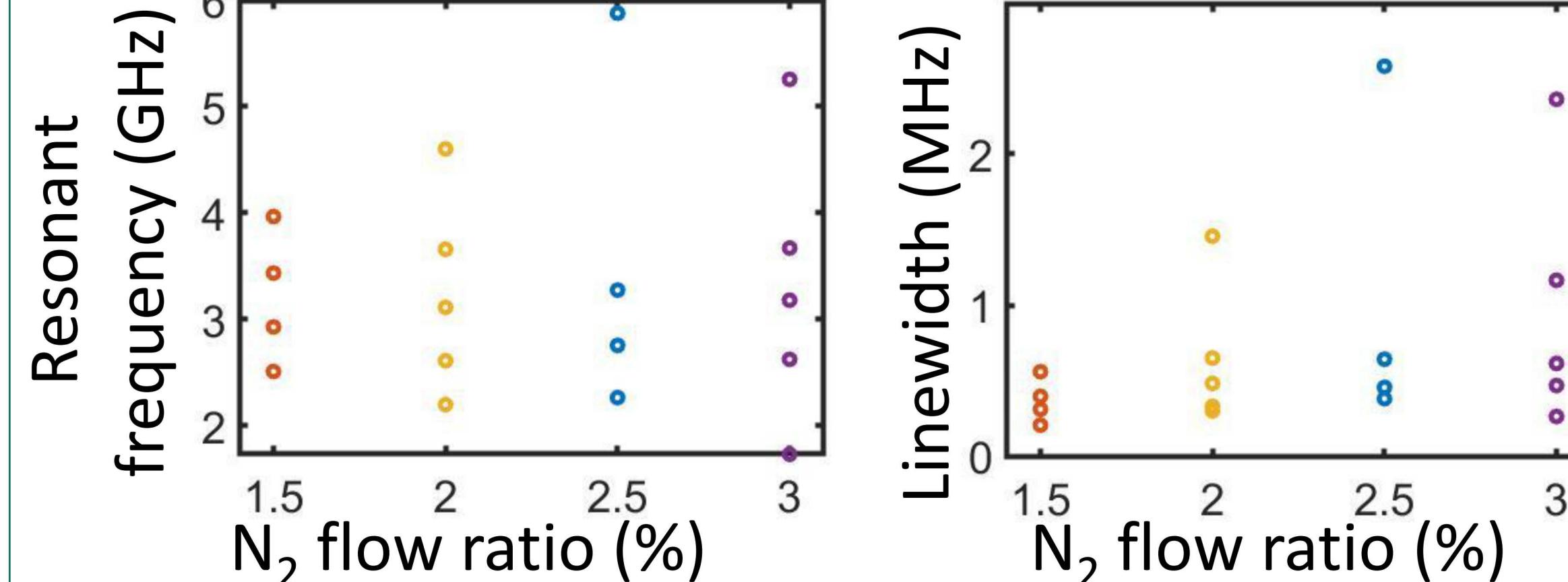


Microwave resonators

- Five transmission line resonators
- S21 Measured at 4 Kelvin up to 6 GHz



N₂ flow ratio effects



Summary

- DC magnetron sputtering processes for ultra thin NbTiN films have been developed and optimized.
- The Resonant frequencies and linewidths of NbTiN transmission line resonators are correlated with thin film properties.